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Aerogel Structures for Photocathodes

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Atomic Layer Deposition (ALD)

- Layer-by-layer thin film synthesis method
- Atomic level control over thickness and composition (even on very large areas)
- Precise coatings on 3-D objects
- Some unique possibilities for morphology control





ALD Reaction Scheme





ALD Thin Film Materials



- Oxide
- Nitride
- Phosphide/Arsenide
- Sulphide/Selenide/Telluride

- Element
- Carbide
- Fluoride
- Dopant



Why Aerogels?

Readily fabricated

•Extraordinary surface area and amplifying ability

•Pseudo-1D e⁻ transport (with many cross links)

•High porosity → improved efficiency

•Multi-component ALD → allows biasing, recharging, efficient electron emission

Dark Current vs Signal -> everywhere the same radius of curvature





Silica Aerogel Coated with ZnO

Before Coating



Weight = 0.0176 g

After Coating

ALD Coating Conditions: 19 Cycles DEZ/H₂O **3 nm ZnO Coating** 10 Torr, 100 s Exposures T=177 °C



Weight = 0.1122 g

Weight Increase =537%



Aerogel Photoelectrodes:

- •High TCO loading (=conductance)
- •Continuous coating by ALD (conductivity measurements and SEM)
- •Growth on TCO platforms
- •High porosity
- Lower manufacturing cost than other PV technologies
- Non-vacuum, low temperature fabrication
- Very tolerant to impurities (no clean room necessary) light absorption and charge separation occur close to interface
- Inexpensive, abundant, benign materials (e.g. TiO₂, ZnO)
- Robust nanoscale process







Carbon Aerogels

Density = 0.082 g/cc Surface area=214 m²/g Manufacturer=Southern Research Institute





Aerogel Coating Conditions:

2) Nucleation Layer: 0.2 nm Al_2O_3 2) Metal Layer: 4 nm W

2 Cycles TMA/H₂O 5 Torr 600-300-600-300 s T=200 °C 15 Cycles Si2H6 (5 Torr)/WF6 (10 Torr) 600-300-600-300 s T=200 °C



EDAX Maps of 10 nm ALD C-Aerogel

Cross section Of ALD Coated and cleaved 1 mm thick middle C-Aerogel:



ALD W extends to middle of 1 mm thick carbon aerogel

edge





W Growth on C Aerogel





Microscopy of W-Coated Carbon Aerogels



Aerogel filament diameter increases with ALD W Cycles



Metal-coated aerogels are pyrophoric!





Conclusions: Aerogels

- Aerogels are one of many nanostructured materials that may be of interest to the detector community.
- Aerogels can be coated allowing the resistivity necessary to provide a kilovolt gradient.
- Abundant surface area means amplification should be achieved over relatively thin structures.
- Large areas are relatively easy to achieve + the self limiting properties of ALD encourages one to believe that these large areas can be uniformly coated.
- Interestingly
 - channel plate detectors achieve uniform flight times with very uniform structures
 - Aerogels would achieve uniformity with random structure averaging
- Remember 2ndary electrons are ejected without memory of their incoming direction.

